

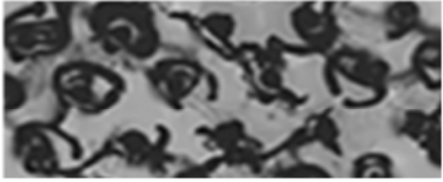
Photoresist removal time and rotation speed	Effect pictures
Single-wafer photoresist removal: 150s Rotation speed: 600PRM	
Single-wafer photoresist removal: 300s Rotation speed: 600PRM	
Single-wafer photoresist removal: 350s Rotation speed: 600PRM	

FIG. 1

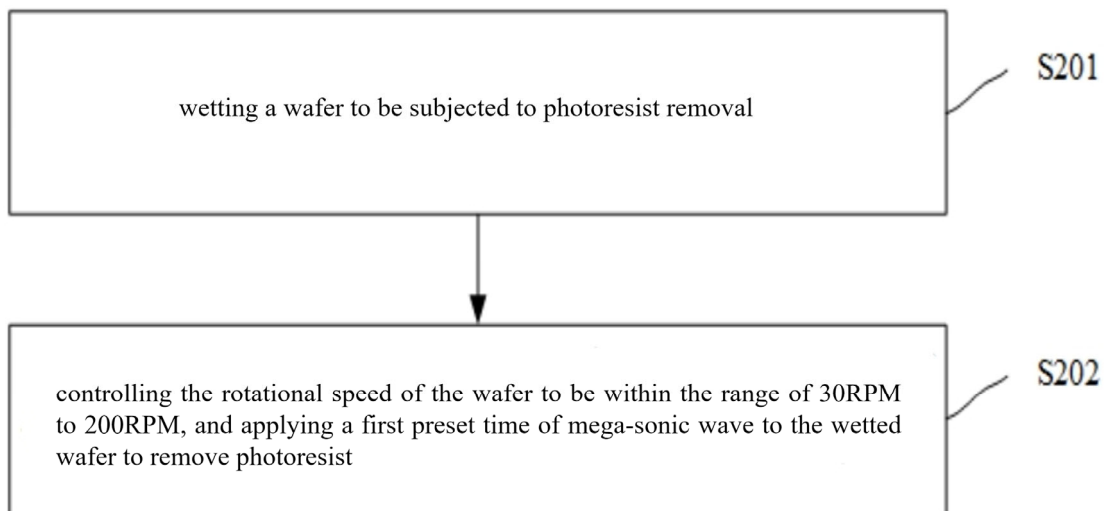


FIG. 2

Photoresist removal time and rotation speed	Effect pictures
Photoresist removal use megasonic wave : 150s Rotation speed: 150PRM	
Photoresist removal use megasonic wave : 300s Rotation speed: 150PRM	
Photoresist removal use megasonic wave : 350s Rotation speed: 150PRM	

FIG. 3

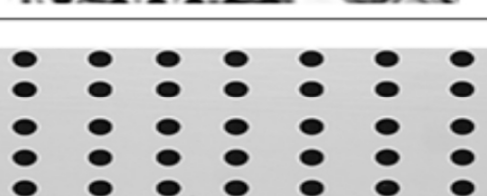
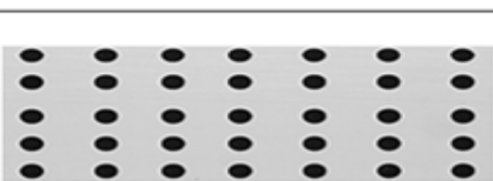
Photoresist removal time and rotation speed	Effect pictures
Photoresist removal use megasonic wave : 150s Rotation speed: 30PRM	
Photoresist removal use megasonic wave : 300s Rotation speed: 30PRM	
Photoresist removal use megasonic wave : 350s Rotation speed: 30PRM	

FIG. 4

Photoresist removal time and rotation speed	Effect pictures
Photoresist removal use megasonic wave : 150s Rotation speed: 200PRM	
Photoresist removal use megasonic wave : 300s Rotation speed: 200PRM	
Photoresist removal use megasonic wave : 350s Rotation speed: 200PRM	

FIG. 5

Photoresist removal time and rotation speed	Effect pictures
Photoresist removal use megasonic wave: 62s Rotation speed: 150PRM	
Photoresist removal use megasonic wave : 124s Rotation speed: 150PRM	
Photoresist removal use megasonic wave : 186s Rotation speed: 150PRM	

FIG. 6

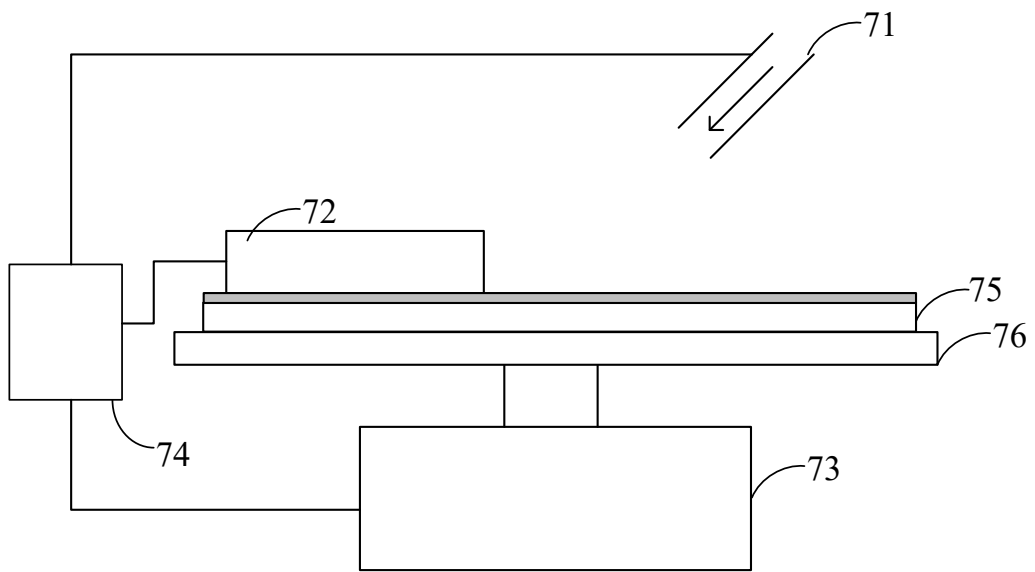


FIG. 7